Electronic Acknowledgement Receipt				
EFS ID:	1290337			
Application Number:	10058854			
International Application Number:				
Confirmation Number:	3704			
Title of Invention:	SYSTEM FOR FORMING A SEMICONDUCTOR DEVICE AND METHOD THEREOF INCLUDING IMPLANTING THROUGH A L SHAPED SPACER TO FORM SOURCE AND DRAIN REGIONS			
First Named Inventor/Applicant Name:	Kay Hellig			
Customer Number:	34456			
Filer:	John Gustav Larson			
Filer Authorized By:				
Attorney Docket Number:	1458.TT4962			
Receipt Date:	03-NOV-2006			
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Application Type:	Utility			

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File Listing:

Document Number	Document Description	File Name	File Size(Bytes)	Multi Part /.zip	Pages (if appl.)
1	Information Disclosure Statement (IDS) Filed	TT4962_IDS_FormSB_08 a.pdf	666210	no	4
Warnings:					

Information:					
2	Fee Worksheet (PTO-875)	fee-info.pdf	8270	no	2
Warnings:					
Information	:				
	Total Files Size (in bytes): 674480				

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New Applications Under 35 U.S.C. 111

If a new application is being filed and the application includes the necessary components for a filing date (see 37 CFR 1.53(b)-(d) and MPEP 506), a Filing Receipt (37 CFR 1.54) will be issued in due course and the date shown on this Acknowledgement Receipt will establish the filing date of the application.

National Stage of an International Application under 35 U.S.C. 371

If a timely submission to enter the national stage of an international application is compliant with the conditions of 35 U.S.C. 371 and other applicable requirements a Form PCT/DO/EO/903 indicating acceptance of the application as a national stage submission under 35 U.S.C. 371 will be issued in addition to the Filing Receipt, in due course.